ANL/MSD/CP--90459 CONF-961202--95

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MIXING OF AL INTO URANIUM SILICIDES REACTOR FUELS*

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November 1996

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To be submitted to the Materials Research Society Meeting, Boston, MA, December 2-6, 1996.

*Work supported by the U.S. Department of Energy, Basic Energy Sciences-Materials Sciences, under contract #W-31-109-ENG-38.

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ABSTRACT

SEM observations have shown that irradiation induced interaction of the aluminum cladding with uranium silicide reactor fuels strongly affects both fission gas and fuel swelling behaviors during fuel burn-up. We have used ion beam mixing, by 1.5 MeV Kr, to study this phenomena. RBS and the ²⁷Al(p, γ) ²⁸Si resonance nuclear reaction to were used to measure radiation induced mixing of Al into U₃Si and U₃Si₂ after irradiation at 300°C.

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Initially U mixes into the AI layer and AI mixes into the U₃Si. At a low doses, the AI layer is converted into UAI₄ type compound while near the interface the phase $U(AI_{.93}Si_{.07})_3$ grows. Under irradiation, AI diffuses out of the UAI₄ surface layer, and the lower density ternary, which is stable under irradiation, is the final product. AI mixing into U₃Si₂ is slower than in U₃Si, but after high dose irradiation the AI concentration extends much father into the bulk. In both systems AI mixing and diffusion is controlled by phase formation and growth. The AI mixing rates into the two alloys are similar to that of AI into pure uranium where similar aluminide phases are formed.

INTRODUCTION

High density reactor fuels are required for either high power density or low uranium enrichment applications. In such applications, particles of the fuel, U₃Si and U₃Si₂, and the cladding, Al, are mixed together and rollbonded together between Al plates. During use of the fuel plates in reactor, the uranium fissions into several ionized fission fragments that produce tracks of damage that may penetrate the interface and result in irradiation induced mixing of the fuel particles and their Al cladding.

The mixing of fuel and cladding is important to the fuel plate swelling behavior [1,2]. Fuel burn-up results in fission products which are approximately 13% Xe and Kr. These inert elements are chemically insoluble in all materials including the fuels. The inert gases precipitate into bubbles that grow by absorbing vacancies and gas atoms. Within the interior of the fuel particles, the diffusion of fission gas to bubbles, becomes the dominant source of fuel swelling and very large bubbles are found on the interior of the fuel particles[3]. However, no visible fission gas bubbles are observed in the mixed layer at the fuel cladding interface. At high fuel particle density, fuel failure can occur when the Al is locally consumed by mixing into a fuel particle. This motivates a study of the details of the irradiation induced mixing of Al into these materials.

A complicating factor is that U₃Si and U₃Si₂ are amorphized by neutrons or 1.5 MeV Kr ions after an irradiation dose of 0.3 dpa at temperatures below 280°C [4,5,6]. Amorphous materials under irradiation undergo plastic flow. In this situation the amorphous U₃Si and U₃Si₂ have little or no strength and catastrophic swelling will occur [1,2].

EXPERIMENTAL

Uranium silicide specimens, U3Si and U3Si2, were produced from an alloys of depleted uranium and silicon that were arc melted and heat treated at 1075 K for 72 hours. The U3Si melt was made Si rich to avoid the presence of free uranium. This resulted in about 10% volume fraction of U3Si2 as a second phase precipitate. The U3Si2 material was single phase. The starting ingots were sliced into wafers that were then polished flat with 0.5 mm Al2O3 grit. The polished wafers were mounted on copper blocks using Sauereisen. The surfaces were polished and coated at room temperature with 200 to 300 nm of Al by electron beam evaporation.

Specimens were irradiated at the 2 MV tandem National Electrostatics ion accelerator facility at Argonne National Laboratory. Irradiations were performed with 1.5 MeV Kr ions at 300°C up to doses of $10^{17}/\text{cm}^2$ for the U₃Si₂ specimens and 6.0 x $10^{16}/\text{cm}^2$ for the U₃Si specimens. The peak in the Kr stopping occurred at 250 nm in the specimens of both alloys with the damage extending to more than 500 nm. The average damage production in the two uranium silicides was 6.0 and 4.8 dpa/(10^{15} ion/cm²) respectively and in the ternary 4.8 dpa/(10^{15} ion/cm²).

Uranium distributions were determined by RBS, using standard curve fitting techniques, with 1.5 to 1.8 MeV He ions. Al concentration profiles were directly measured by resonance nuclear reaction of 27Al(p, γ)28Si which occurs at a proton energy of 991.9 keV with a FWHM of 100 eV.

RESULTS

RBS spectra taken from U3Si and U3Si2 specimens after 1.5 MeV Kr ion irradiations to different doses and at a temperature of 300°C are plotted in **Figure 1** and **Figure 2** respectively. Because of the large mass differences, these RBS spectra are only sensitive to back scattering from uranium atoms. No changes were detected during annealing at 300°C before irradiation. RBS spectra in Figure 1 and Figure 2 indicate that the mixing rate is higher in U3Si than that in U3Si2. The depth dependence of the AI concentrations were independently determined by use of the resonance nuclear reaction of 27 Al(p, γ) 28 Si. The gamma intensities are plotted in **Figure 3** for U₃Si and in **Figure 4** for U₃Si₂. After 10¹⁶ Xe/cm² the phase U₂₅Al₇₀Si₅ has formed in U₃Si. A similar composition is found in U₃Si₂ but the mixed layer is not as uniform, and the inward diffusion of Al into U₃Si₂ is much greater.

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Figure 1 RBS spectra from AI/U₃Si irradiated by 1.5 MeV Kr ions at 300°C. Irradiation doses: 0.3, 0.6 and 1.0x10¹⁶ Kr/cm²



Figure 3 27 Al(p, γ) intensities from Al/U₃Si after 1.5 MeV Kr irradiation at 300°C to doses of: 0.3, 0.6 and 1.0x10¹⁶ Kr/cm²



Figure 2 RBS spectra from AI/U₃Si₂ irradiated by 1.5 MeV Kr ions at 300°C. Irradiation doses: 0.6, 1.0 and 3.0x10¹⁶ Kr/cm²





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Schematics of deconvolutions of the RBS and p- γ spectra for irradiated U₃Si is shown in Figure 5. Indications from SEM observation after in pile irradiation of these alloys suggested that AI is the diffusing species into both uranium alloys [1]. However after our lowest dose, the RBS measurements show that U atoms are found throughout the AI layer, and the p- γ measurements show that AI atoms are found in the U₃Si far from the initial interface. This indicates that both U and AI are mobile during irradiation at 300°C. As U atoms diffuse into the AI, a phase of the form UAI₄ forms and grows at a rapid rate. As AI diffuses into the U₃Si, a phase of the type UAI₃ forms. As the irradiation continues, AI diffuses out of the UAI₄ phase and the UAI₃ type phase extends to the surface.



Figure 5 Schematic of Mixing of an AI layer on U_3Si at 300°C. Ion doses are indicated next to each section of the figure.

The growth rate of the stable $U(AI_{.93}Si_{.07})_3$ phase is controlled by Al diffusion out of the UAI₄ type phase and through the existing $U(AI_{.93}Si_{.07})_3$ layer. The RBS and p- γ measurements indicate the formation of a uniform mixed region with composition of $U_{25}AI_{70}Si_5$. This phase is found after melting U₃Si and Al [7]. Once this phase formed, its composition was unchanged by additional irradiation. Mixing of Al into U₃Si₂ follows the same sequences.

Phase formation also controls the mixing of AI into pure U [8]. The mixing in this system was rapid, and during Xe irradiation the mixed region evolved from UAI₄ to UAI₃ to UAI₂ as AI diffused out of the mixed layer. Mixing with Ar ions resulted in the formation of UAI₄ without the observation of intermediate phases. At 450K, the phase layer grew at a rate of 10^{-9} Å²cm² and, the mixing was too rapid to allow determination of diffusion coefficients. This rate is similar to that of AI mixing with U₃Si, and AI mixing into U₃Si is about twice as fast as into U₃Si₂.

SUMMARY

The mixing between AI and uranium silicides is controlled by the diffusions of AI and U atoms leading to phase formation. U diffusion into the initial AI over layer results in formation of a UAI₄ surface layer, while AI diffusion into U_3Si results in $U_{25}AI_{70}Si_5$. AI diffusion out of the UAI₄ surface layer, through the growing $U_{25}AI_{70}Si_5$ layer controls mixing at 300°C. After the UAI₄ layer is consumed, the $U_{25}AI_{70}Si_5$ mixed layer is stable during continued irradiation. The mixing rate of AI into U₃Si is about twice as fast as into U₃Si₂ and is similar to that of AI mixing into U by Ar ions at same temperature.

ACKNOWLEDGMENT

We should like to thank B. Kestel for specimen preparation. Work supported by the US department of Energy, Office of Basic Energy Science, under Contract W-31-109-Eng-38 at Argonne National Laboratory.

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